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APPLICATION NO.	FI	LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/500,253	0/500,253 06/25/2004		Kenji Ito	Q81941 8926		
23373	7590	03/27/2006		EXAMINER		_
SUGHRUE 1	MION,	PLLC	ELVE, MARIA ALEXANDRA			
2100 PENNSYLVANIA AVENUE, N.W.				ART UNIT	PAPER NUMBER	-
SUITE 800 WASHINGTO	ON. DC	20037	1725	-	-	

DATE MAILED: 03/27/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

		<i>A</i>
	Application No.	Applicant(s)
Office Action Commence	10/500,253	ITO ET AL.
Office Action Summary	Examiner	Art Unit
	M. Alexandra Elve	1725
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING D.  Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).
Status		
1) Responsive to communication(s) filed on 05 Ja	action is non-final.  nce except for formal matters, pro	
Disposition of Claims		
4) ☐ Claim(s) 1-10 is/are pending in the application 4a) Of the above claim(s) is/are withdray 5) ☐ Claim(s) is/are allowed.  6) ☐ Claim(s) 1-10 is/are rejected.  7) ☐ Claim(s) is/are objected to.  8) ☐ Claim(s) are subject to restriction and/or	wn from consideration.	
Application Papers		
9) ☐ The specification is objected to by the Examine 10) ☑ The drawing(s) filed on 25 June 2004 is/are: a Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct	)⊠ accepted or b)□ objected to drawing(s) be held in abeyance. Set tion is required if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).
11)☐ The oath or declaration is objected to by the Ex	caminer. Note the attached Office	Action or form PTO-152.
Priority under 35 U.S.C. § 119		
a) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority document application from the International Bureau * See the attached detailed Office action for a list	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	on No ed in this National Stage
Attachment(s)		
1) Notice of References Cited (PTO-892)	4) Interview Summary	
Notice of Draftsperson's Patent Drawing Review (PTO-948)     Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)     Paper No(s)/Mail Date	Paper No(s)/Mail Do 5) Notice of Informal P 6) Other:	ate Patent Application (PTO-152)

#### **DETAILED ACTION**

## Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1 & 4-5 are rejected under 35 U.S.C. 102(b) as being anticipate by Owen et al. (USPN 5,841,099).

Owen et al. discloses the use of laser pulses to form vias in a multilayered target. A first laser output of high power density processes the metallic layer while a second lower power density processes the dielectric layer. Energy densities range from 2.3 to 28.72 J/cm², (one being 14.87 J/cm²). In one preferred embodiment, a first laser output of high intensity is used to process the metallic layer and a second laser output of equal intensity and greater spot size is used to process an underlying dielectric layer.

Conventional CO² lasers typically generate laser output wavelengths of about 10.6 um. (abstract, figures, col. 2, lines 44-67, col. 3, lines 1-50, col. 11, lines 25-49, cols. 13-14)

# Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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Claims 2-3 & 6 are rejected under 35 U.S.C. 103(a) as being unpatentable over Owen et al. as stated in the above paragraph and further in view of Hino (USPN 6,037,103).

Owen et al. discloses the use of a resin and a range of energy densities but does not teach the presence of a polyimide or an energy density less than 2.3 J/cm<sup>2</sup>.

Hino discloses a method for forming holes in a printed wire board. The resin layer is not particularly limited as long as holes can be formed therein by a laser beam output from a laser source and it has an electric insulating property. Examples of the resin include polyester resin, epoxy resin, urethane resin, polystyrene resin, polyethylene resin, polyamide resin, polyimide resin, ABS resin, polycarbonate resin, silicone resin and the like. Of these resins, polyimide resin having superior heat resistance, chemical resistance and mechanical strength is preferred.

The energy density for resin and debris removal is 500 mJ/cm<sup>2</sup> (that is, 0.5 J/cm<sup>2</sup>). (abstract, figures, col. 4, lines 50-60, col. 7, lines 10-15, col. 8, lines 24-60, col. 9, lines 50-65, col. 10, lines 13-50)

It would have been obvious to one of ordinary skill in the art at the time of the invention to use a polyimide resin and an energy density of 0.5 J/cm², as taught by Hino, in the Owen et al. processing because polyimide is a resin and has superior properties and energy densities of greater than 0.2 J/cm² are required in order to reach the residue decomposition energy threshold, thus 0.5 J/cm² meets the threshold without cause undue board damage.

Claim 7 is rejected under 35 U.S.C. 103(a) as being unpatentable over Owen et al. and Hino as stated in the above paragraph and further in view of Kurosawa et al. (USPN 6,373,026)

Owen et al. and Hino teach a processing time of about 5 ms but not 10us.

Kurosawa et al. discloses a laser beam machining method for a wiring board. The beam irradiation time ranges from 10 to 200 us, with an energy density of about 20 J/cm2 or more. Thus the wiring board may be drilled to form a through-hole, a blind via hole, grooving and cutting. (abstract, figures, col. 2, lines 55-67, col. 3, lines 25-35, col. 4,lines 40-50, col. 5, lines 15-40, col. 10, lines 15-45, col. 11, lines 33-40, col. 12,lines 9-14)

It would have been obvious to one of ordinary skill in the art at the time of the invention to use a processing time, as taught by Kurosawa et al., in the Owen et al. and Hino process because shorter processing times optimize the manufacturing process and minimize damage.

### Response to Arguments

Applicant's arguments filed 1/5/06 have been fully considered but they are not persuasive. Applicant argues that Owen only teaches a single laser beam and does not disclose a CO<sub>2</sub> laser. The examiner respectfully disagrees and notes that in one preferred embodiment, a first laser output of high intensity is used to process the metallic layer and a second laser output of equal intensity and greater spot size is used

to process an underlying dielectric layer. Conventional CO<sup>2</sup> lasers typically generate laser output wavelengths of about 10.6 um.

#### Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to M. Alexandra Elve whose telephone number is 571-272-1173. The examiner can normally be reached on 6:30-3:00 Monday to Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Patrick J. Ryan can be reached on 571-272-1292. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

March 20, 2006.

M. Alexandra Elve Primary Examiner 1725